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APPLICATION NO.	F	ILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/725,384		12/03/2003	Koyu Asai	67161-134	34 4977	
•	7590	04/24/2006		EXAMINER		
McDermott, 600 13th Stree		Emery	ANDUJAR, LEONARDO			
Washington, DC 20005-3096			ART UNIT	PAPER NUMBER		
•				2826		
				DATE MAILED, 04/24/2004		

Please find below and/or attached an Office communication concerning this application or proceeding.

			H.D					
	Application No.	Applicant(s)						
	10/725,384	ASAI ET AL.						
Office Action Summary	Examiner	Art Unit	-					
	Leonardo Andújar	2826						
The MAILING DATE of this communication Period for Reply	appears on the cover sheet wi	th the correspondence address						
A SHORTENED STATUTORY PERIOD FOR RE	PLY IS SET TO EXPIRE 3 M	ONTH(S) OR THIRTY (30) DAYS						
WHICHEVER IS LONGER, FROM THE MAILING  - Extensions of time may be available under the provisions of 37 CF after SIX (6) MONTHS from the mailing date of this communication  - If NO period for reply is specified above, the maximum statutory pe  - Failure to reply within the set or extended period for reply will, by s' Any reply received by the Office later than three months after the n earned patent term adjustment. See 37 CFR 1.704(b).	G DATE OF THIS COMMUNIC R 1.136(a). In no event, however, may a ro n. eriod will apply and will expire SIX (6) MON tatute, cause the application to become AB	CATION.  Peply be timely filed  THS from the mailing date of this communication.  ANDONED (35 U.S.C. § 133).						
Status								
1) $\boxtimes$ Responsive to communication(s) filed on $Q$	3 February 2006.							
2a) This action is <b>FINAL</b> . 2b) ⊠	This action is <b>FINAL</b> . 2b)⊠ This action is non-final.							
3) Since this application is in condition for allo	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is							
closed in accordance with the practice und	ler <i>Ex parte Quayle</i> , 1935 C.D	. 11, 453 O.G. 213.						
Disposition of Claims								
4)⊠ Claim(s) <u>1-5 and 7-11</u> is/are pending in the	e application.							
	4a) Of the above claim(s) is/are withdrawn from consideration.							
5)⊠ Claim(s) <u>1-5</u> is/are allowed.		•						
6)⊠ Claim(s) <u>7-11</u> is/are rejected.								
7) Claim(s) is/are objected to.	•	•						
8) Claim(s) are subject to restriction ar	nd/or election requirement.							
Application Papers								
9) The specification is objected to by the Exar	niner							
10) The drawing(s) filed on is/are: a)		by the Examiner.						
Applicant may not request that any objection to								
Replacement drawing sheet(s) including the co		•						
11) ☐ The oath or declaration is objected to by the	e Examiner. Note the attached	Office Action or form PTO-152.						
Priority under 35 U.S.C. § 119								
12)⊠ Acknowledgment is made of a claim for fore	eian priority under 35 U.S.C. §	119(a)-(d) or (f).						
a)⊠ All b)□ Some * c)□ None of:								
1. Certified copies of the priority docum	nents have been received.							
2. Certified copies of the priority docum		pplication No	,					
3. Copies of the certified copies of the	priority documents have been	received in this National Stage						
application from the International Bu	reau (PCT Rule 17.2(a)).							
* See the attached detailed Office action for a	list of the certified copies not	received.						
Attachment(s)								
1) Notice of References Cited (PTO-892)		Summary (PTO-413) s)/Mail Date						
<ul> <li>2) Notice of Draftsperson's Patent Drawing Review (PTO-948</li> <li>3) Information Disclosure Statement(s) (PTO-1449 or PTO/St</li> </ul>		nformal Patent Application (PTO-152)						
Paper No(s)/Mail Date	6) Other:							

# **DETAILED ACTION**

## Continued Examination Under 37 CFR 1.114

1. A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on 02/03/2006 has been entered.

2.

# Claim Rejections - 35 USC § 102

3. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 4. Claims 7-11 are rejected under 35 U.S.C. 102(b) as being anticipated by Harper et al. (US 6,150,723).
- 5. Regarding claim 7, Harper (e.g. fig. 1) shows a semiconductor device comprising: a first wiring 12, a first interlayer film 11b formed over the wiring; a plurality of vias 14 formed in the interlayer film and connected to the first wiring; a second inter layer film formed 15 formed in the vicinity of the vias and formed in the first interlayer film; wherein the second interlayer film is extended in a longitudinal direction of the via.

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6. Regarding claim 8, Harper teaches that the second interlayer film is a SiN film (col. 4/lls. 30-37).

- 7. Regarding claim 9, Harper teaches that the first interlayer film is a low k film (e.g. dielectric material; col. 3/lls. 12-21).
- 8. Regarding claim 10, Harper teaches that the interlayer film is arranged around the via.
- 9. Regarding claim 11, Harper implicitly teaches that the stress of the second interlayer film is higher than the stress of the first interlayer film. In this case, the trench 12 or the wiring 12 provide stress to the via 14, liner 15 and insulating layer 11. As shown by Harper, the surface area of the liner (i.e. the area were the force is applied) is less than the area of the insulating layer, therefore, it is expected that the stress of the second interlayer film to be higher than the stress of the first interlayer film.

#### Allowable Subject Matter

10. Claims 1-5 are allowed.

### Response to Arguments

11. Applicant's arguments filed on 02/03/2006 have been considered but are moot in view of the new ground(s) of rejection.

#### Conclusion

12. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Leonardo Andújar whose telephone number is 571-272-

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1912. The examiner can normally be reached on Mon through Thu from 9:00 AM to 7:30 PM EST.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nathan J. Flynn can be reached on 571-272-1915. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Status information for Patent Application Information Retrieval (PAIR) system. published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic

Business Center (EBC) at 866-217-9197 (toll-free).

04/10/2006